

EDITORS

Senior Editors:

S. Z. D. Cheng T. Hashimoto

Honorary Editors:

R. K. Eby Y. Imanishi I. M. Ward

Asian Editors:

Professor C. C. Han (*all subject areas from China*)
Joint Laboratory of Polymer Science and Materials,
Institute of Chemistry, The Chinese Academy of Sciences,
Zhongguancun, Beijing, 100080, China.

Professor K. Tashiro (*physics*)

Department of Future Industry-oriented Basic Science and Materials,
Graduate School of Engineering, Toyota Technological Institute,
Hisakata 2-12-1, Tempaku, Nagoya 468-8511, Japan.

Professor S. Ito (*physical chemistry and functionality*)

Department of Polymer Chemistry, Graduate School of Engineering,
Kyoto University, Katsura Campus, Kyoto 615-8510, Japan.

Professor T. Masuda (*chemistry and synthesis*)

Department of Polymer Chemistry, Graduate School of Engineering,
Kyoto University, Katsura Campus, Kyoto 615-8510, Japan.

Editors for the Americas:

Professor S. Z. D. Cheng (*physics and physical chemistry*)

Maurice Morton Institute and Department of Polymer Science,
Goodyear Polymer Centre, Room 936, University of Akron, Akron,
OH 44325-3909, USA

Professor F. W. Harris (*chemistry and synthesis*)

Maurice Morton Institute and Department of Polymer Science,
Goodyear Polymer Centre, Room 617, University of Akron, Akron,
OH 44325-3909, USA

European & Rest of the World

(*outside the Americas and Asia*) *Editors:*

Professor G. Krausch (*physics*)

Physikalische Chemie II, Universität Bayreuth, D-95440 Bayreuth,
Germany

Professor S. Förster (*physical chemistry*)

Institut für Physikalische Chemie, Universität Hamburg,
Bundesstraße 45, 20146 Hamburg, Germany

Professor A. H. E. Müller (*chemistry and synthesis*)

Makromolekulare Chemie II, Universität Bayreuth,
D-95440 Bayreuth, Germany

Computational and Theoretical Polymer Science Editor:

Professor J. E. Mark

Department of Chemistry, University of Cincinnati,
Cincinnati, OH 45221-0172, USA

EDITORIAL ADVISORY BOARD

A. Abe Tokyo Institute of Polytechnics, Japan	P. Hodge University of Manchester, UK	S. B. Ross-Murphy King's College, London, UK
W. W. Adams Rice University, TX, USA	B. S. Hsiao State University of New York, NY, USA	G. C. Rutledge Massachusetts Institute of Technology, Cambridge, MA, USA
M. Antonietti Max Planck Institute of Colloids and Interfaces, Potsdam, Germany	M. B. Huglin University of Salford, UK	A. J. Ryan University of Sheffield, UK
D. C. Bassett University of Reading, UK	R. A. L. Jones University of Sheffield, UK	S. Sakurai Kyoto Institute of Technology, Japan
N. C. Billingham University of Sussex, UK	T. Kajiyama Kyushu University, Japan	I. Sanchez University of Texas, Austin, TX, USA
D. C. Bott National Starch & Chemical, High Wycombe	F. Khouri National Institute of Standards and Technology, Gaithersburg, MD, USA	K. Schmidt-Rohr Iowa State University, IA, USA
R. H. Boyd University of Utah, Salt Lake City, UT, USA	J. K. Kim Pohang University of Science and Technology, Pohang, Korea	M. Shibayama University of Tokyo, Japan
W. Burghardt Northwestern University, Evanston, IL, USA	T. Kitayama Department of Chemistry, Osaka University, Japan	R. A. Siegel University of Minnesota, Minneapolis, USA
B. Charleux Université Pierre et Marie Curie, Paris, France	L. Leibler ESPCI, Paris, France	P. Smith ETH Zürich, Switzerland
F. Ciardelli University of Pisa, Italy	A. Ledwith Wigan, UK	R. Stepto University of Manchester, UK
R. J. Composto University of Pennsylvania, PA, USA	P. J. Lemstra Eindhoven University of Technology, The Netherlands	G. Strobl Albert-Ludwigs-Universität, Freiburg, Germany
J. M. G. Cowie Heriot-Watt University, Edinburgh, UK	B. A. Lotz Institut Charles Sadron, Strasbourg, France	U. W. Suter ETH Zürich, Switzerland
F. Du Prez Ghent University (RUG), Ghent, Belgium	A. J. Lovinger Bell Laboratories, Lucent Technologies, Murray Hill, NJ, USA	P. L. Taylor Case Western Reserve University, Cleveland, OH, USA
B. Farmer Wright-Patterson Airforce Base, OH, USA	C. Macosko University of Minnesota, Minneapolis, MN, USA	E. L. Thomas Massachusetts Institute of Technology, Cambridge, MA, USA
W. J. Feast University of Durham, UK	R. H. Marchessault McGill University, Montreal, Canada	M. Tsuji Kyoto University, Japan
C. W. Frank Stanford University, CA, USA	K. Matyjaszewski Carnegie Mellon University, Pittsburgh, PA, USA	F. Wang The Chinese Academy of Science, Beijing, P. R. China
J. Fried University of Cincinnati, OH, USA	J. E. McGrath Virginia Polytechnic Institute and State University, Blacksburg, VA, USA	Z. Y. Wang Carleton University, Ottawa, Canada
R. G. Gilbert University of Sydney, NSW, Australia	M. A. Meador NASA-Lewis Research Center, Cleveland, OH, USA	R. M. Waymouth Stanford University, CA, USA
S. Granick University of Illinois at Urbana-Champaign, Urbana, IL, USA	E. W. Meijer Eindhoven University of Technology, The Netherlands	G. Wegner Max-Planck-Institute for Polymer Research, Mainz, Germany
Y. Gnanou ENSCPB-Université Bordeaux I, Talence, France	M. Muthukumar University of Massachusetts, Amherst, MA, USA	J. G. Williams Imperial College, London, UK
R. H. Grubbs California Institute of Technology, Pasadena, CA, USA	H. Nishide Waseda University, Japan	A. H. Windle University of Cambridge, Cambridge, UK
C. J. Hawker IBM Almaden Research Center, San Jose, UK	D. R. Paul University of Texas, Austin, TX, USA	C. Wu The Chinese University of Hong Kong, Shatin, Hong Kong
J. N. Hay University of Birmingham, UK	R. E. Prud'homme Université de Montréal, Montréal, Canada	Q. F. Zhou Peking University, Beijing, China
P. M. Hergenrother NASA-Langley Research Center, Hampton, VA, USA	R. A. Register Princeton University, Princeton, NJ, USA	